8th International Conference on Hot-Wire Chemical Vapor Deposition (HWCVD)

Event - 8th International Conference on Hot-Wire Chemical Vapor Deposition (HWCVD) ↻

Title	8th International Conference on Hot-Wire Chemical Vapor Deposition (HWCVD)
When	Mo, 13. Oktober 2014 - Do, 16. Oktober 2014

Description

8th International Conference on Hot-Wire Chemical Vapor Deposition (HWCVD)

Following the success of the 7th International Conference on Hot-Wire Chemical Vapor Deposition (HWCVD) in October 2012 in Osaka City, Japan the HWCVD 8 Conference October 13 – 16, 2014 takes place in Braunschweig, Germany

The conference is jointly organized by the Fraunhofer-Institute for Surface Engineering and Thin Films IST (Germany) and the INPLAS Network of Competence Industrial Plasma Surface Technology (Germany).

For further information and for registration please visit the official conference website: hwcvd.fraunhofer.de

To submit an abstract please visit the HWCVD website.
Please note that your registration with the conference is required before you can upload your abstract.
Abstract templates are provided at HWCVD website.
The deadline for the abstract submission is May 26, 2014.

The program committee will review all abstracts and decide whether the paper is presented orally or as a poster.

Venue - Braunschweig

Location	Braunschweig
County	Braunschweig
Country	DE